PATENT ABSTRACTS OF JAPAN

(11)Publication number:

2002-081152

(43)Date of publication of application: 22.03.2002

(51)Int.CI.

E04B 2/02 E04B 1/02

(21)Application number: 2000-270219

(71)Applicant: JAPAN SCIENCE & TECHNOLOGY

CORP

(22)Date of filing:

06.09.2000

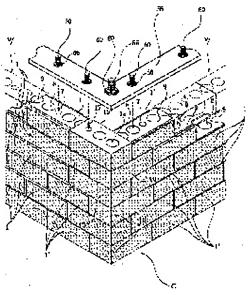
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(54) BRICK MASONRY STRUCTURE, BRICK MASONRY METHOD AND BRICK MANUFACTURING METHOD

(57)Abstract:

PROBLEM TO BE SOLVED: To provide a brick masonry structure, a masonry method and a manufacturing method capable of being fitted to every sectional structure of various buildings such as corner section, opening section, column type or the like.

SOLUTION: Bricks 1; 1'; 10; 20; 30; 40 and metal plates 51; 52; 55 are laminated, and the bricks are integrally connected to each other under prestress by tightly clamping bolts 60 passing through vertical bolt insertion holes 7; 17; 27; 37; 47. The bricks also have vertical passing—through holes 8; 18; 28; 38; 48 with a large diameter. In a corner section connecting the bricks at a specific angle, the passing—through holes are vertically arranged in a projected corner section or a recessed corner section wall cross area to form a continuous vertical hole, a longer bolt 65 having a comparatively large diameter is inserted into the vertical holes, and a nut 69 is clamped to the upper end of the longer bolt. In the opening frame part or the column type part, the passing—through holes and the bolt insertion holes are alternately arranged in the



vertical direction and are stood in a row in the vertical direction. A nut 70 forming a clamper is inserted into the passing—through holes. Both up and down bricks are integrally connected under prestress by clamping the bolts 60 to the nuts in the passing—through holes.

LEGAL STATUS

[Date of request for examination]

10.03.2003

[Date of sending the examiner's decision of rejection]

[Kind of final disposal of application other than the examiner's decision of rejection or application converted registration]

[Date of final disposal for application]

[Patent number]

[Date of registration]

[Number of appeal against examiner's decision of rejection]

[Date of requesting appeal against examiner's decision of rejection]